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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
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10/563,030

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Roland Steffen

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EXAMINER

AKINYEMI, AJIBOLA A

ART UNIT

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PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

Office Action Summary	Application No. 10/563,030	Applicant(s) STEFFEN ET AL.	
	Examiner AJIBOLA AKINYEMI	Art Unit 2618	

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) ☒ Responsive to communication(s) filed on 08 January 2009.
- 2a) ☐ This action is **FINAL**. 2b) ☒ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) ☒ Claim(s) 1,3-12 and 14-19 is/are pending in the application.
- 4a) Of the above claim(s) _____ is/are withdrawn from consideration.
- 5) ☐ Claim(s) _____ is/are allowed.
- 6) ☒ Claim(s) 1,3-12 and 14-19 is/are rejected.
- 7) ☐ Claim(s) _____ is/are objected to.
- 8) ☐ Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☒ The drawing(s) filed on 30 December 2005 is/are: a) ☒ accepted or b) ☐ objected to by the Examiner.
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

- 12) ☒ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☒ All b) ☐ Some * c) ☐ None of:
1. ☒ Certified copies of the priority documents have been received.
2. ☐ Certified copies of the priority documents have been received in Application No. _____.
3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

* See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

- | | |
|--|---|
| 1) <input checked="" type="checkbox"/> Notice of References Cited (PTO-892) | 4) <input type="checkbox"/> Interview Summary (PTO-413) |
| 2) <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948) | Paper No(s)/Mail Date. _____ |
| 3) <input type="checkbox"/> Information Disclosure Statement(s) (PTO/SB/08) | 5) <input type="checkbox"/> Notice of Informal Patent Application |
| Paper No(s)/Mail Date _____ | 6) <input type="checkbox"/> Other: _____ |

DETAILED ACTION

1. A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on 01/08/2009 has been entered.

Claim Rejections - 35 USC § 103

2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

3. The factual inquiries set forth in *Graham v. John Deere Co.*, 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:

1. Determining the scope and contents of the prior art.
2. Ascertaining the differences between the prior art and the claims at issue.
3. Resolving the level of ordinary skill in the pertinent art.
4. Considering objective evidence present in the application indicating obviousness or nonobviousness.

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Claims 1, 5-7, 10-12 and 14-19 are rejected under 35 U.S.C. 103(a) as being unpatentable over Weiler et al (U.S. Patent No. 5970395) and further in view of Seike (Patent No.: US 6243576B1).

With respect to claim 1:

Weiler discloses a high-frequency measuring system for measuring a device under test (fig.4, item 15), comprising: a measuring-device unit (fig.4, item 5); and a first high-frequency module (fig.4, item 3A) including a transmitter device (col.6, lines 28-31) configured to communicate with the device under test (fig.4, item 15) and a second high-frequency module (fig.4, item 3B) including a receiver device (col.6, lines 28-31) configured to communicate with the device under test (fig.4, item 15), wherein each high-frequency module is placed spatially separated from the measuring-device unit (fig.4, item 5) and each high-frequency module is connected to the measuring-device unit via a digital interface (fig.4, item 4) wherein the measuring-device unit (fig.4, item 5) is configured to process input data input into the measuring-device unit to form a bitstream for transmission via the digital interface to the one first high-frequency module and the first high-frequency module is configured to subsequently forward the bitstream to the device under test using the transmitter device (col.4, lines 53-col.5, lines 16). Weiler did not disclose state diagram of I and Q (In phase and Quadrature). Seike discloses processing of an input data including I and Q (fig.2, col.9, lines 1-13). It would have been obvious to one of ordinary skill in the art at the time the invention was made to have I and Q data in order to improve quality of signal by reducing noise through

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proper signal conversion as well as user can customize design data by tuning input data.

With respect to claims 5 and 6:

Weiler further discloses the high-frequency measuring system used digital interface is an optical interface and electrical interface (see col.2 lines 33-41).

With respect to claim 7:

Weiler furthermore discloses the high-frequency measuring system comprises portable computer (15 of fig.4) i.e. device under test [frequency module] wherein supplying power independently from monitoring unit (5) through power cable (16 of fig.4) [Moreover, every receiver component essentially provided an electrical energy through power supply for its operation].

With respect to claim 10:

Weiler further discloses A high-frequency measuring system according to claim 1, wherein control data or user data is transmitted in a standardized form via the digital interface, and wherein the first high-frequency module comprises means for processing a high- frequency signal with regard to the transmission of data in standardized form via the digital interface or for processing the data transmitted in standardized form with regard to at least one predetermined transmission standard for the high-frequency signal (col.6, lines 13-53).

With respect to claim 11:

The rejection of claim 1 is incorporated; Seike further discloses a high frequency measuring system wherein the input data is manually input by one of the operating key (col.7, lines 56-61).

With respect to claim 12:

Weiler discloses a high-frequency measuring system for measuring a device under test (fig.4, item 15), comprising a measuring-device unit (fig.4, item 5) for receiving input data from a user and a first high-frequency module (fig.4, item 3A) including a transmitter device (col.6, lines 28-31) configured to communicate with the device under test (fig.4, item 15) and a second high-frequency module (fig.4, item 3B) including a receiver device (col.6, lines 28-31) configured to communicate with the device under test, wherein each high-frequency module (fig.4, item 3A....3N) is placed spatially separated from the measuring-device unit (fig.4, item 5) and each high-frequency module is connected to the measuring-device unit via a digital interface (fig.4, item 4) wherein the receiver device is configured to receive a message comprising a high-frequency signal originating from the device under test (fig.4 is showing that item 3A...3N is communicating with device under test item 15), the second high-frequency module (fig.4, item 3B) being configured to process the high- frequency signal to form a first bitstream for transmission via the digital interface (fig.4, item 4) to the measuring-device unit (fig.4, item 5) wherein in the measuring-device unit is configured to process the input data to form a second bitstream for transmission via the digital interface to the one first high-frequency module (fig.4, item 3A...3N) and the first high-frequency

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module (fig.4, item 3A) is configured to subsequently forwarded forward the second bitstream to the device under test (fig.4, item 15) using the transmitter device (col.6, lines 28-31). Weiler did not disclose converting the high-frequency signal to an intermediate-frequency signal and digitizing the intermediate-frequency signal for transmission via the digital interface to the measuring-device unit for evaluation of the message. Seike discloses high frequency module whereby high frequency signal is being converted into intermediate frequency and digitizing the intermediate-frequency signal for transmission (fig. 2, input RF/IF section goes to item 60). It would have been obvious to one of ordinary skill in the art at the time the invention was made to have intermediate frequency in order to improve quality of signal by reducing noise through proper signal conversion.

With respect to claims 14:

The rejection of claim 12 is incorporated; Seike further discloses a high-frequency measuring system wherein the conversion of the high-frequency signal to an intermediate-frequency signal includes receiving the high-frequency signal at the receiver device and subsequently mixing the high- frequency signal with a signal generated by a first local oscillator (fig13).

With respect to claims 15:

Seike further discloses high-frequency measuring system wherein the intermediate-frequency signal is subdivided into an in-phase branch and a quadrature-phase branch

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and mixed in the in-phase branch with a signal generated by a second local oscillator (fig.15A).

With respect to claim 16:

Weiler discloses a high-frequency measuring system for measuring a device under test (fig.4, item 15), comprising: a measuring-device unit (fig.4, item 5); and a first high-frequency module (fig.4, item 3A) including a transmitter device (col.6, lines 28-31) configured to communicate with the device under test (fig.4, item 15) and a second high-frequency module (fig.4, item 3B) including a receiver device (col.6, lines 28-31) configured to communicate with the device under test (fig.4, item 15), wherein each high-frequency module is placed spatially separated from the measuring-device unit (fig.4, item 5) and each high-frequency module is connected to the measuring-device unit via a digital interface (fig.4, item 4) wherein the measuring-device unit (fig.4, item 5) is configured to process input data input into the measuring-device unit to form a bitstream for transmission via the digital interface to the one first high-frequency module and the first high-frequency module is configured to subsequently forward the bitstream to the device under test using the transmitter device (col.4, lines 53-col.5, lines 16).

Weiler did not disclose state diagram of I and Q (In phase and Quadrature) and converting the high-frequency signal to an intermediate-frequency signal and digitizing the intermediate-frequency signal. Seike discloses processing of an input data including I and Q (fig.2, col.9, lines 1-13) and converting the high-frequency signal to an intermediate-frequency signal and digitizing the intermediate-frequency signal (fig. 2,

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input RF/IF section goes to item 60). It would have been obvious to one of ordinary skill in the art at the time the invention was made to have I and Q data and converting the high-frequency signal to an intermediate-frequency signal in order to for improve quality of signal by reducing noise through proper signal conversion as well as user can customize design data by tuning input data.

With respect to claim 17:

Weiler further discloses to determine a specific bit sequence to be transmitted to the computer (15 of fig.4) i.e. device under test (see fig.4).

With respect to claim 18:

Weiler further discloses to generate one or more control signals in the bit sequence by the scanned controller to control the one high- frequency module (3 of fig.4) (see fig. 5 and col.5 lines 10-32).

With respect to claim 19:

The rejection of claim 16 is incorporated; Seike further discloses a method wherein the input data is input by the user using one of the operating keys (fig.1B).

4. Claim(s) 3, 4, 8 and 9 are rejected under 35 U.S.C. 103(a) as being unpatentable over Weiler as modified by Seike as applied to claim 1 above and further

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in view of Agilent PNA Network Analyzers (NPL documents: priority date September 25,2002).

With respect to claims 3, 4, 8 and 9:

The rejection of claim 1 is incorporated; Weiler and Seike do not disclose explicitly that interface is serial and parallel (although, it is an obvious for any test measurement/network analyzers ports have been provided serial or parallel interface). However, Standard documents of Agilent PNA Network Analyzers (RF and microwave frequency measurement device wherein high RF frequency, antenna measurement and frequency calibration performed by network analyzers) teaches connectivity of network analyzers uses variety (i.e. multiple ports) input/output interfaces including universal serial bus, LAN and parallel connections; and plurality of ports can be seen both side of front view of the analyzers are identical; and plurality of different ports are used in the network analyzers (measurement devices) for digital interface(see all figures @ page 8 standard features). Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to have interface in serial and parallel pattern which are some identical and some are different ports for using interface as taught by standard documents of Agilent PNA Network Analyzers to obtain more clear signal, error free to use probe for connection (since some ports are identical) and good adaptability (using digital interface) of the measuring devices.

Response to Arguments

5. Applicant's arguments with respect to claims 1, 12 and 16 have been considered but are moot in view of the new ground(s) of rejection.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to AJIBOLA AKINYEMI whose telephone number is (571)270-1846. The examiner can normally be reached on monday- friday (8.30-5pm) Est.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, YUWEN PAN can be reached on (571) 272-7855. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

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AA

/Yuwen Pan/

Primary Examiner, Art Unit 2618